UNIVERSITY OF MICHIGAN



COLLEGE OF ENGINEERING
THE RADIATION LABORATORY
DEPARTMENT OF ELECTRICAL ENGINEERING
AND COMPUTER SCIENCE

3228 EECS BUILDING 1301 BEAL AVENUE ANN ARBOR, MICHIGAN 48109-2122 734 764-0500 FAX 734 647-2106 http://www.eecs.umich.edu/RADLAB/

Re: Certification for Continental Transmitter

FCC ID: M3NA2C738448 IC: 7812A-A2C738448

REQUEST FOR CONFIDENTIALITY

Pursuant to FCC 47 CRF 0.457(d) and 0.459 and IC RSP-100, Section 10, Continental requests that a part of the subject application be held confidential. Continental has spent substantial effort in developing this product and it is one of the first of its kind in industry. Having the subject information easily available to "competition" would negate the advantage they have achieved by developing this product. Not protecting the details of the design will result in financial hardship.

Type of Confidentiality Requested			Exhibit
Short Term	Permanent	(1)	ID Label & Location
Short Term	Permanent	(3)	External Photos
Short Term	\square Permanent ¹	(4)	Block Diagram
Short Term		(5)	Schematics
Short Term	Permanent	(7)	Test Setup Photos
Short Term	Permanent	(8)	User's Manual
Short Term	Permanent	(9)	Internal Photos
Short Term		(10)	Parts List & Placement
Short Term	Permanent	(11)	RF Exposure
Short Term	Permanent	(12)	Description of Operation
1. Block Diagram includes internal oscillator frequency information that the manufacturer considers to be proprietary.			

Permanent Confidentiality: Continental requests the exhibits listed above as permanently confidential be permanently withheld from public review.

Short-Term Confidentiality (FCC Only): Continental requests the exhibits selected above as short term confidential be withheld from public view for a period of 45 days from the date of the Grant of Equipment Authorization and prior to marketing.

If there are any questions regarding this request, please contact me at the above address or call 734-483-4211, fax 734-647-2106 or e-mail liepa@umich.edu.

Sincerely.

Valdis V. Liepa, Research Scientist

University of Michigan

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